

Symposium | Symposium | Advanced CMOS Technology and Its Future Scope

[11p-B5-1~9]Advanced CMOS Technology and Its Future Scope

Wed. Mar 11, 2015 1:15 PM - 5:30 PM B5 (6B-105)

△ : Young Scientist Oral Presentation Award Applied

▲ : English Presentation

▼ : Both Award Applied and English Presentation

4:30 PM - 5:00 PM

[11p-B5-8]High-k Metal Gate Process Technology and Challenges for 10 nm and Beyond

ONaomi Yoshida¹, Adam Brand¹ (1.Applied Materials)

Keywords: Metal Gate, High-k, FinFET